

AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

Claims 1-22 (canceled).

Claim 23 (currently amended): A method for fabricating a semiconductor device, the method including:

forming an amorphous silicon film on a substrate;

preprocessing the amorphous silicon film by modifying the amorphous silicon film to prepare the amorphous silicon film to be made polycrystalline;

laser processing the amorphous silicon film modified through the preprocessing step for producing a polycrystalline silicon film; and

laser power inspecting/extracting

for inspecting for the presence of a foreign object or an abnormality in the preprocessing step by imaging by use of the amorphous silicon film having undergone the preprocessing step, and

~~for determining a laser power based on a predetermined inspection performed on a predetermined region~~ performing laser preprocessing on a predetermined region of the amorphous silicon film having undergone the preprocessing while varying laser power as an irradiated spot moves, and performing inspection using spectroscopy at each of a plurality of positions at which the laser processing has been performed at different laser powers, to determine a laser power based on a result of the inspection; wherein

the laser processing step uses the laser power determined in the laser power inspection/extraction step.

Claim 24 (canceled).

Claim 25 (currently amended): The method of claim-24 23, wherein the spectroscopy is performed at a measurement wavelength of about 700 nm to about 800 nm.

Claims 26 and 27 (canceled).

Claim 28 (currently amended): The method of claim-24 23, wherein the inspection using the spectroscopy is performed with measurement light shining on a measurement spot from around the measurement spot.

Claim 29 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes performing an inspection adjacent laser processing equipment that performs the laser processing in the laser processing step.

Claims 30 and 31 (canceled).

Claim 32 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes setting a measurement fixed-quantity value against which to evaluate measurement results.

Claim 33 (previously presented): The method of claim 32, wherein the measurement fixed-quantity value is determined by using equipment having a calibration substrate placed thereon and provided with a function for performing calibration.

Claim 34 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes automatically determining an optimum laser power value

and automatically feeding the automatically determined optimum laser power value to laser processing equipment.

Claim 35 (previously presented): The method of claim 23, wherein the laser processing step includes using a laser power about 5 mJ or about 10 mJ lower than an optimum laser power value determined in the laser power inspection/extraction step.

Claim 36 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes performing multiple-point measurement inspection on the polycrystalline silicon film.

Claim 37 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes inspecting, before the laser processing, the film on the substrate to find a ratio of amorphous silicon film to polycrystalline silicon film.

Claim 38 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes inspecting, after the laser processing, the film on the substrate to find a ratio of amorphous silicon film to polycrystalline silicon film.

Claim 39 (previously presented): The method of claim 23, wherein the laser power inspection/extraction step includes inspecting, both before and after the laser processing, the film on the substrate to find a ratio of amorphous silicon film to polycrystalline silicon film.

Claims 40-44 (canceled).